

Attorney Docket No.: SSI-00501

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Maximilian A. Biberger et al.

Serial No.: 09/912,844

Filed: July 24, 2001

HIGH PRESSURE PROCESSING For:

CHAMBER FOR

SEMICONDUCTOR SUBSTRATE

Group Art Unit: 1763

Examiner: Ram N. Kackar

AMENDMENT AND RESPONSE TO OFFICE ACTION MAILED ON

August 14, 2003

162 North Wolfe Road Sunnyvale, California 94086

(408) 530-9700

Customer No.: 28960

Mail Stop Non-Fee Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

In Response to the Office Action mailed on August 14, 2003, please amend the abovetitled application as follows:



Date: 10-31-03 By Atum D. Russon

<u>PATENT</u> Attorney Docket No.: SSI-00501

IN THE UNITED STATES PATE	NT AND TRADEMARK OFFICE
In re Application of:	Group Art Unit: 1763 Examiner: Ram N. Kacker
Maximilian A. Biberger et al.	TRANSMITTAL LETTER
Serial No.: 09/912,844) 162 North Wolfe Road
Filed: July 24, 2001) Sunnyvale, California 94086) (408) 530-9700
For: HIGH PRESSURE PROCESSING CHAMBER FOR SEMICONDUCTOR SUBSTRATE) Customer Number 28960
Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450	
Sir:	
Enclosed please find an Amendment an	d Response to the Office Action mailed on
August 14, 2003 for filing with the U.S. Paten	t and Trademark Office.
The Commissioner is authorized to char	rge any additional fee or credit any
overpayment to our Deposit Account No. <u>08-1</u>	275. An originally executed duplicate of this
transmittal is enclosed for this purpose.	
Re	spectfully submitted,
HA	AVERSTOCK & OWENS LLP
Dated: October 31, 2003 OCTOB	By: Mung B. Haverstock Reg. No.: 32,571 Attorneys for Applicants